COMPLETE LISTING OF THE CLAIMS

The following lists all of the claims that are or were in the above-identified patent application. The status identifiers respectively provided in parentheses following the claim numbers indicate the current statuses of the claims.

- 1. (Original) A device comprising:
- a first magnetic region;
- a second magnetic region;
- a control region that forms a first interface with the first magnetic region and a second interface with the second magnetic region; and
- a wire positioned relative to the control region so that a current through the wire creates in the control region a magnetic field that rotates spins of the electrons traversing the control region.
- 2. (Original) The device of claim 1, wherein the control region is such that an electron spin relaxation time of the control region is longer than a transit time of the electrons traversing control region.
- 3. (Original) The device of claim 1, wherein the control region comprises a semiconductor material.
- 4. (Original) The device of claim 3, wherein the semiconductor material is selected from a group consisting of Si, Ge, GaAs, InAs, GaP, GaInAs, ZnSe, and ZnCdSe.
 - 5. (Original) The device of claim 3, wherein the semiconductor material is n-type.
- 6. (Original) The device of claim 1, wherein each of the first and second magnetic regions comprises a ferromagnetic material.
- 7. (Original) The device of claim 1, wherein the first magnetic region has a first magnetization, the second magnetic region has a second magnetization, and the first and second magnetizations are fixed at a relative angle selected to give the device a desired electrical characteristic.
 - 8. (Original) The device of claim 1, further comprising terminals that permit

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PH: (408) 927-6700 FX: (408) 927-6701 biasing of the first and second magnetic regions to cause injection of spin-polarized electrons through the first interface into the control region so that the second interface acts as a spin filter with a resistance depending on spin orientation of the spin-polarized electrons in the control region, near the second interface.

- 9. (Original) The device of claim 1, wherein a bias voltage applied between the first and second magnetic regions causes injection of spin-polarized electrons through the control region between the first magnetic region and the second magnetic region.
- 10. (Previously Presented) The device of claim 1, wherein a fixed bias voltage is applied between the first and second magnetic regions, and a first current through the wire changes a second current between the first and second magnetic regions.
- 11. (Original) The device of claim 1, further comprising an insulating material disposed to electrically insulate the wire from the control region, the first magnetic region, and the second magnetic region.
 - 12. (Currently Amended) A device comprising:
 - a magnetic wire;
 - a magnetic region; and
- a control region forming a first interface with the magnetic wire and a second interface with the magnetic regions region, wherein:

the first and second interfaces selectively permit spin-polarized electrons to cross between the magnetic wire and the magnetic region; and

- a current along the magnetic wire creates in the control region a magnetic field that rotates spins of the electrons traversing the control region.
- 13. (Original) The device of claim 12, wherein the control region is such that an electron spin relaxation time of the control region is longer than a transit time of the electrons traversing control region.
- 14. (Original) The device of claim 12, wherein the control region comprises a semiconductor material.
 - 15. (Original) The device of claim 14, wherein the semiconductor material is

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16. (Original) The device of claim 14, wherein the semiconductor material is n-type.

17. (Original) The device of claim 12, wherein the magnetic wire comprises a ferromagnetic material.

18. (Original) The device of claim 12, wherein the magnetic region comprises a ferromagnetic material.

19. (Original) The device of claim 12, wherein the magnetic wire has a first magnetization, the magnetic region has a second magnetization, and the first and second magnetizations are fixed at a relative angle selected to give the device a desired electrical characteristic.

20. (Original) The device of claim 12, wherein a bias voltage applied between the magnetic wire and the magnetic region causes injection of spin-polarized electrons through the control region between the magnetic wire and the magnetic region.

21. (Original) The device of claim 12, wherein a fixed bias voltage is applied between the magnetic wire and the magnetic region, and a first current through the magnetic wire changes a second current between the magnetic wire and the magnetic region.

Claims 22 to 38 (Canceled)

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